



2443-15

Winter College on Optics: Trends in Laser Development and Multidisciplinary Applications to Science and Industry

4 - 15 February 2013

Femtosecond laser micromachining - introduction (part 1)

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Outline of the presentation

- Nonlinear light-matter interaction, photoinduced material modifications
- Femtosecond laser optical waveguide writing
- Fabrication of integrated photonic devices
 - passive devices
 - > active devices
 - > polarisation control

What will come next

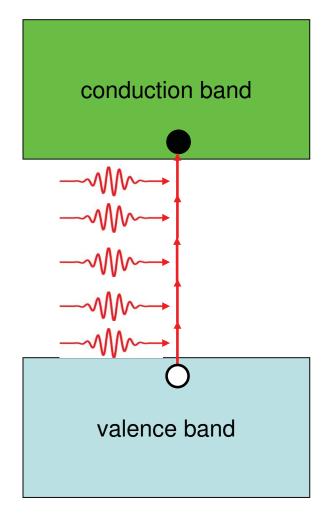
- Fabrication of microchannels and fully integrated microoptofluidic devices
- Surface structuring and texturing
- Two-photon polimerisation





Material modification following nonlinear light absorption





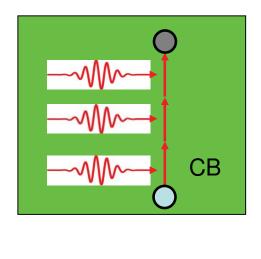
 Simultaneous absorption of k photons brings electron from valence to conduction band

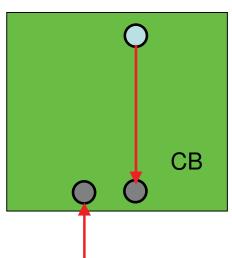
$$\frac{dn}{dt} = \sigma_k I^k(t)$$

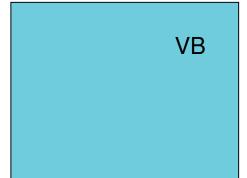
n(t) electron density

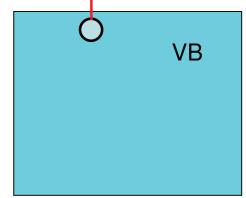
I(t) laser intensity

 σ_k k-photon absorption cross section









• Free electrons in the conduction band are accelerated by the laser field until they have enough kinetic energy to kick another electron into the conduction band

$$\frac{dn}{dt} = \alpha I(t)n(t)$$

α avalanche ionization coefficient



Femtosecond vs long-pulse absorption

Femtosecond absorption

- The peak power is sufficient to trigger, in the focus, multiphoton ionization which provides a seed of electrons in the conduction band
- The electrons are accelerated by the laser and multiplied by avalanche ionization ⇒ deterministic and highly reproducible process

Long pulse absorption

- The peak power is too low for multiphoton ionization
- Avalanche ionization initiated by spurious free electrons in the conduction band from defects or impurities ⇒ poorly reproducible process

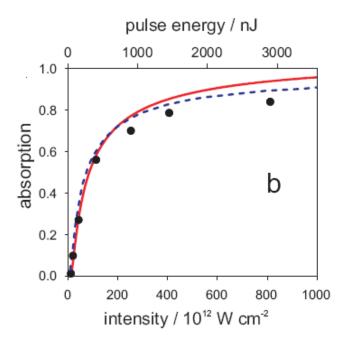




Femtosecond vs long-pulse absorption

Femtosecond absorption

- The peak power is sufficient to trigger, in the focus, multiphoton ionization which provides a seed of electrons in the conduction band
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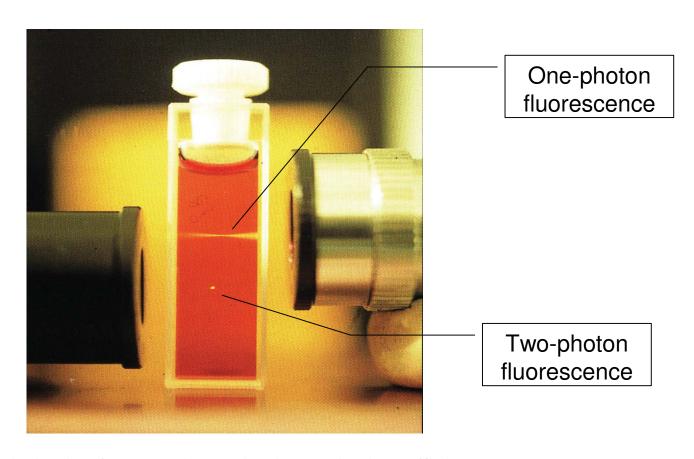
Femtosecond pulse absorption as a function of peak intensity (Rayner *et al.*, Opt. Express **13**, 3208 (2005))

Highly localized and reproducible deposition of energy in the focus of the laser beam





One photon vs multiphoton absorption

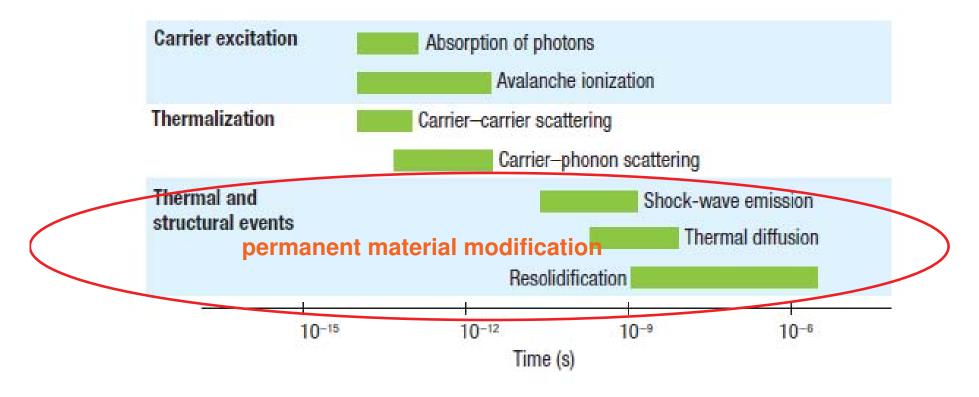


Light is absorbed only in the focus, where the intensity is sufficient

W. Denk et al., Science 248, 73 (1990)



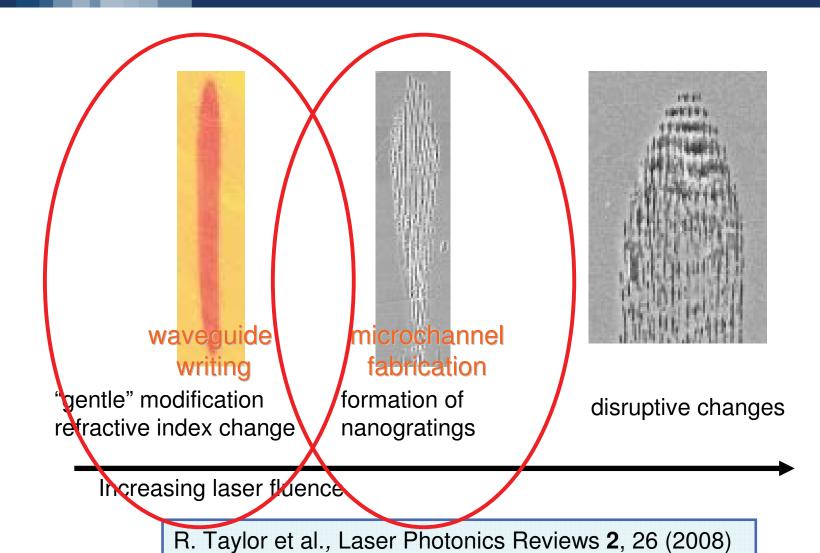
Timescales of light-matter interaction in transparent materials



R. Gatass and E. Mazur, Nature Photonics 2, 219 (2008)











Femtosecond laser optical waveguide writing

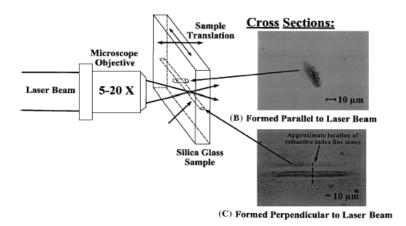


November 1, 1996 / Vol. 21, No. 21 / OPTICS LETTERS 1729

Writing waveguides in glass with a femtosecond laser

K. M. Davis, K. Miura, N. Sugimoto, and K. Hirao

Hirao Active Glass Project, Exploratory Research for Advanced Technology, Research Development Corporation of Japan, 15 Mori Moto-Cho, Shimogamo, Sakyo-Ku, Kyoto G06, Japan



Seminal paper by Hirao et al., demonstrating permanent positive refractive index changes





Origins of refactive index change

Not yet fully understood, several mechanisms have been proposed such as:

- Structural modifications, i.e. changes in the structure of the glass network
- Color center formation, with UV absorption causing a refractive index change through Kramers-Krönig
- Melting and rapid resolidification (quenching), causing regions of material densification

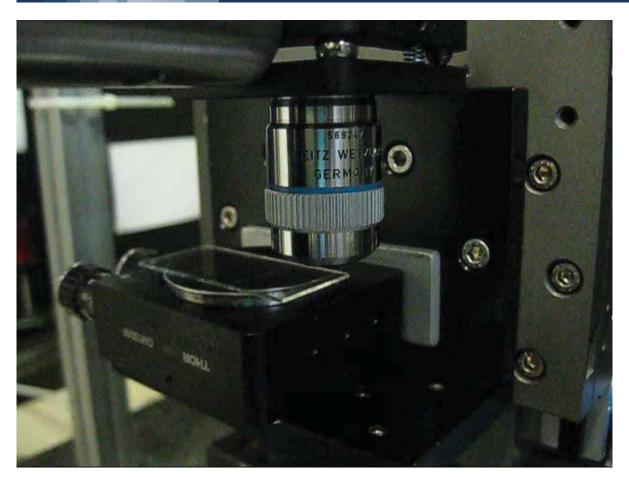
These mechanisms may act simultaneously.

A.M. Streltsov et al., J. Opt. Soc. Am. B 19, 2496 (2002)





Femtosecond waveguide writing



Waveguides are fabricated by **translation** of the sample.

ADVANTAGES

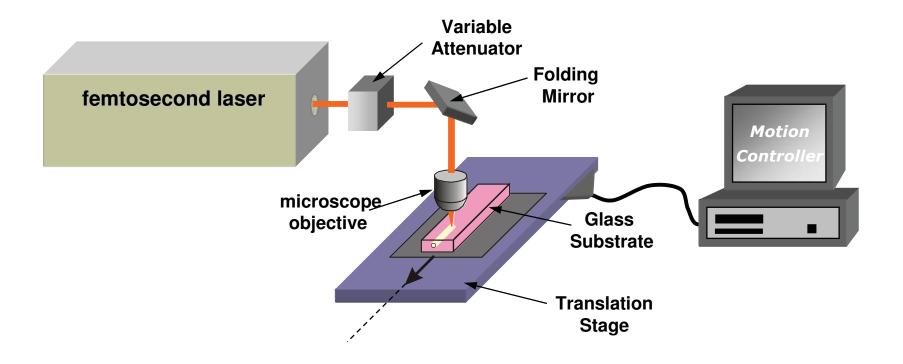
Single step, no need for photolithography

Three-dimensional photonic circuits

Fast and cheap prototyping

Applicable to a wide variety of substrates





The basic setup is remarkably simple: laser, focusing optics, computercontrolled translation stage





Lasers used in waveguide fabrication

Amplified Ti:Sapphire systems: 100-200 fs long pulses at 800nm, few μJ energies per pulse, 1-200 kHz repetition rate

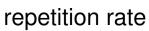
single-pulse regime

Diode-pumped fiber or bulk Yb lasers: 300-400 fs long pulses at 1040nm, < 1 μJ energies per pulse,200 kHz-2 MHz repetiton rate

cumulative regime

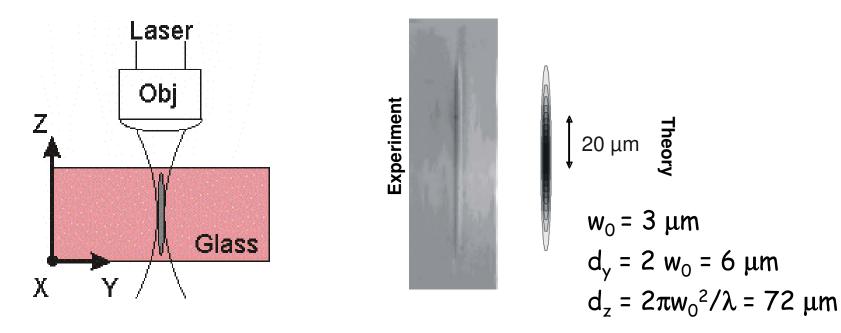
■ Long-cavity Ti:Sapphire oscillators: 10-50 fs long pulses at 800nm, tens of nJ energy per pulse, 4-25 MHz repetition rate

Cumulative regime: pulse period much shorter than heat diffusion time out of the focal volume





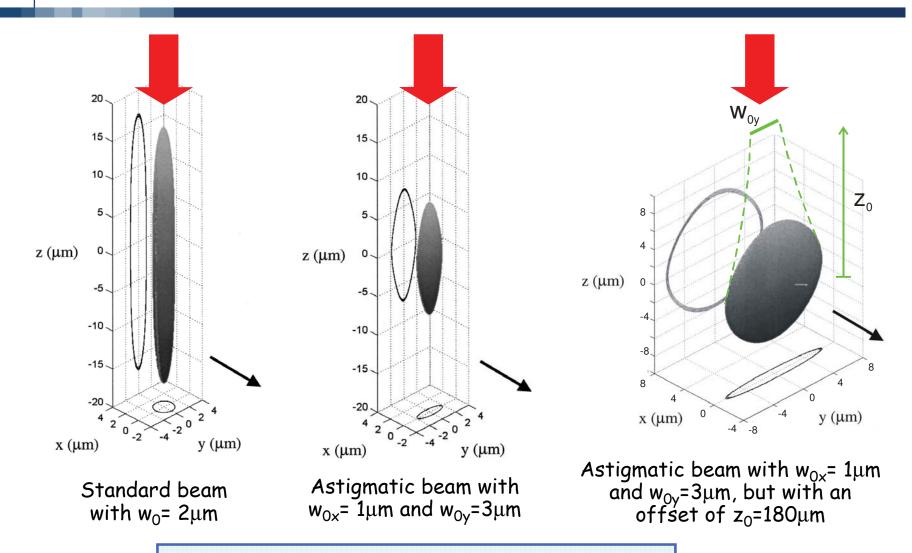
■ In transverse geometry, writing with low repetition rate systems provides waveguides with an intrinsically asymmetric cross section → very poor coupling with standard fibers



The confocal parameter is much larger than the focal diameter



Solution: astigmatic beam shaping

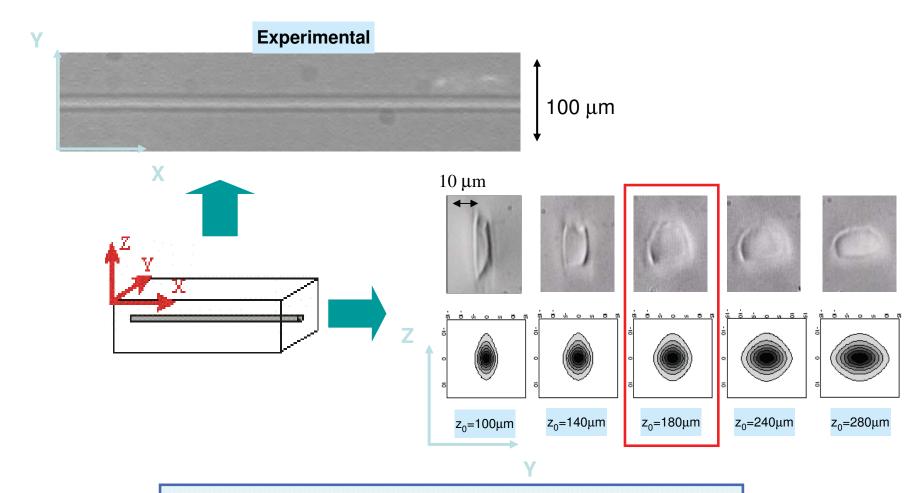


G. Cerullo et al., Optics Letters 27, 1938 (2002)





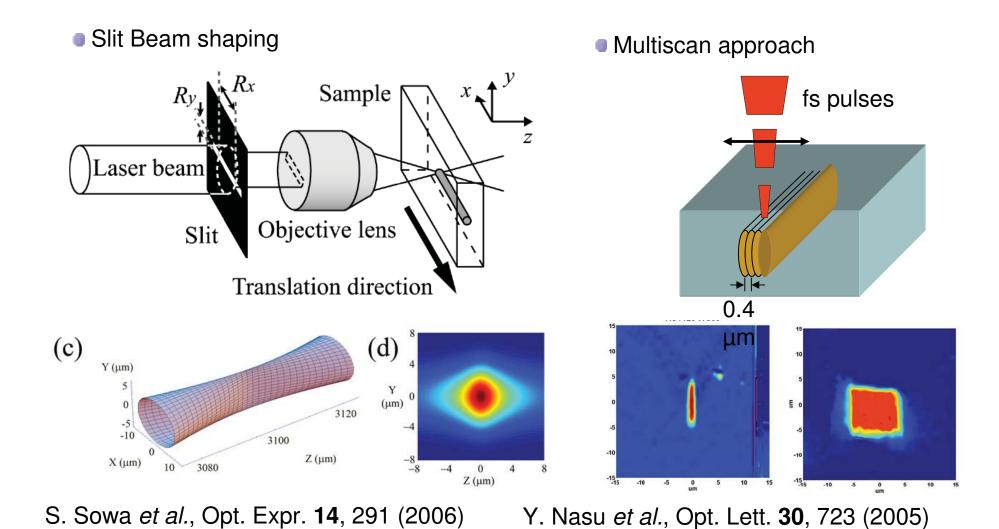
Astigmatic beam shaping: experimental results



R. Osellame et al., J. Opt. Soc. Am. B 20, 1559 (2003)



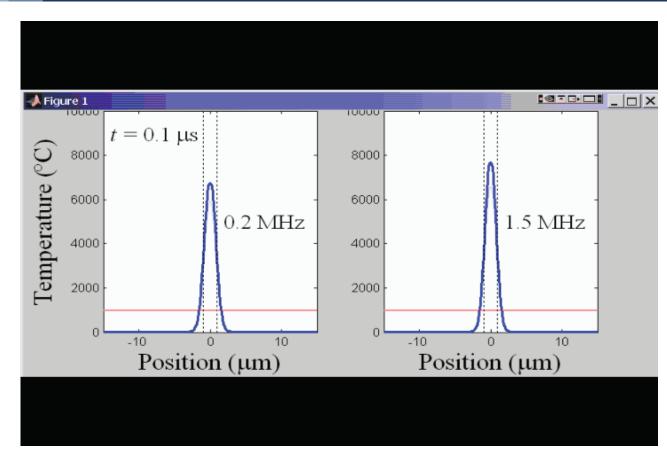








Heat accumulation effects in waveguide writing



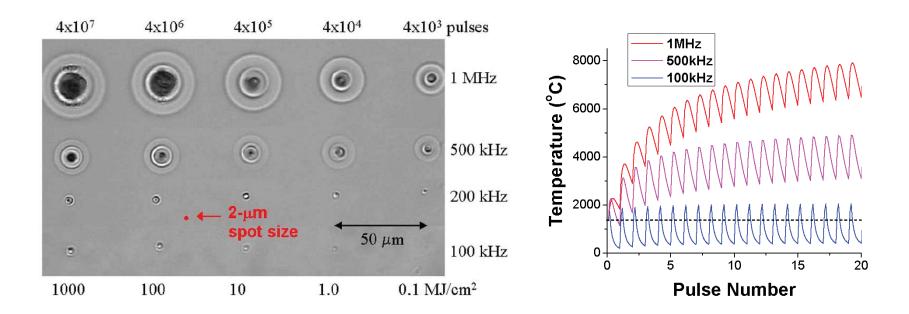
Borosilicate glass. Heat diffusion time out of focal volume ~1 μs

S. Eaton et al., Opt. Express 16, 9443 (2008)





Waveguide writing in the cumulative regime



- Due to isotropic heat diffusion, waveguide cross section becomes symmetric
- Waveguide cross-section can be controlled by average power and translation speed
 - S. Eaton et al., Opt. Express 13, 4708 (2005)
 - C. Schaffer et al., Appl. Phys. A 76, 351 (2003)



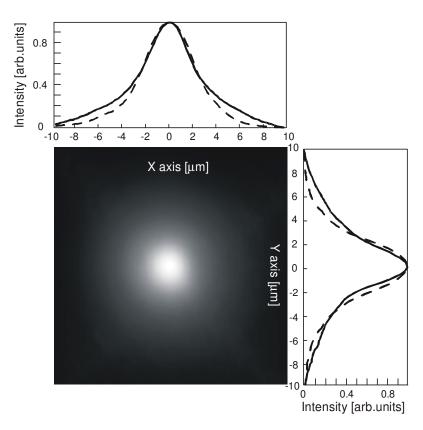


Passive photonic devices by femtosecond writing





Waveguides mode matched to telecom fibers



- Single transverse mode waveguides with high circular symmetry at 1.5 μm.
- Mode matching with standard telecom fibers: 0.2 dB coupling losses (propagation losses < 0.2 dB/cm)



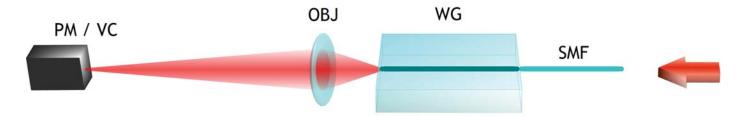
- Output mode characterization (2D intensity profile)
- Losses measurements: IL = $10 \log_{10} \left(\frac{P_{out}}{P_{in}} \right)$

for straight waveguides (length l): $IL = CL + FL + PL \cdot l$

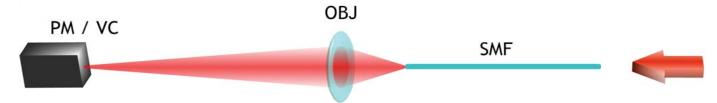
Polarization behaviour characterization



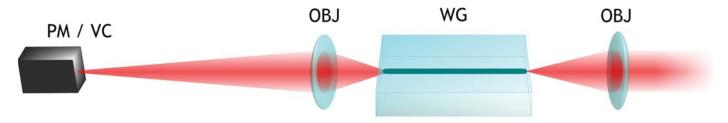
Output mode profile and losses



Laser light from a single mode fiber (SMF) is coupled to the waveguide (WG). An objective (OBJ) images the output facet of the waveguide onto a power meter head (PM), for measuring the transmitted power, or onto a videocamera (VC), for measuring the intensity profile of the guided mode.



The waveguide is removed and the collection setup is used for measuring the power or the mode profile of a SMF.

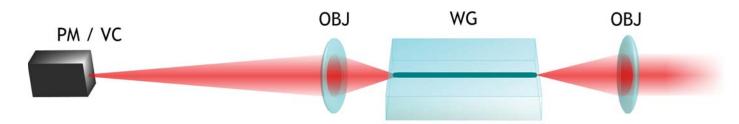


A free-space laser beam is coupled to the waveguide through an objective; the collection setup is analogous to the previous case.

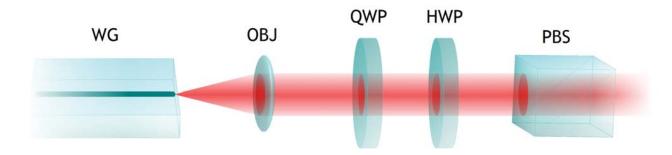




Polarization behaviour



No optical fibers are used for light coupling to preserve polarization of the input light



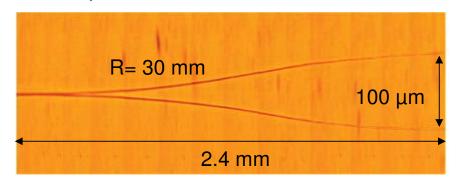
A polarizing beam splitter (PBS), a half-wave plate (HWP) and a quarter-wave plate (QWP) are used to manipulate the polarization of the input light, in order to perform measurements of the polarization behaviour of the device.

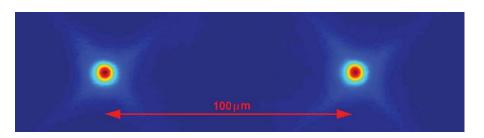




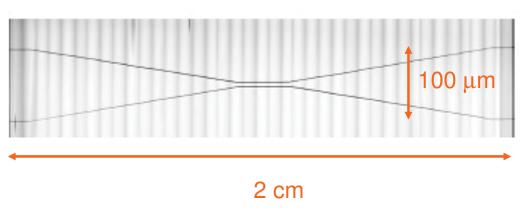
Planar photonic devices

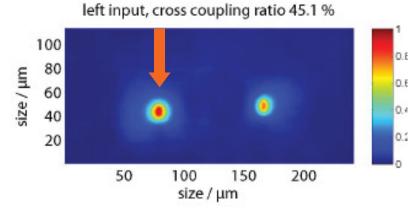
Splitter





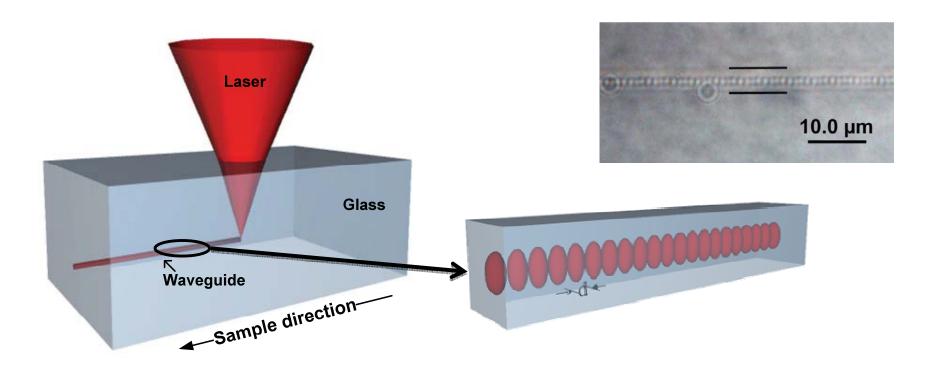
Directional coupler







Bragg grating waveguide fabrication: single pulse method



Laser is scanned rapidly, so individual shots create periodic index modulation

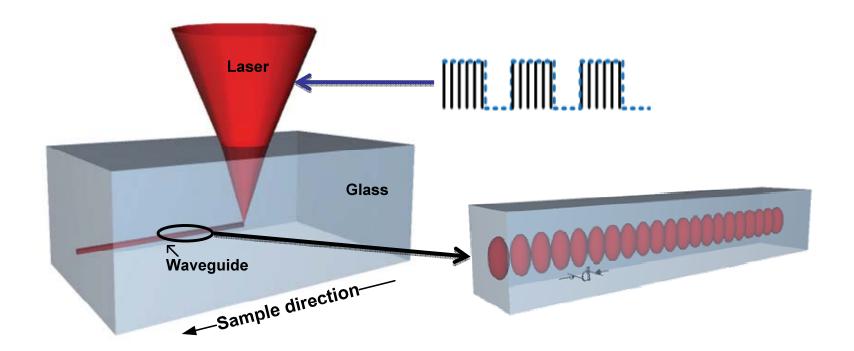
G.D Marshall et al., Opt. Lett. 31, 2690 (2006)

H. Zhang et al., Opt. Lett. **31**, 3495 (2006)





Bragg grating waveguide fabrication: burst method

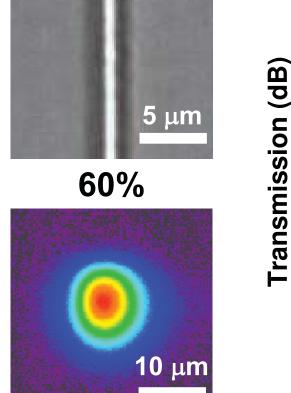


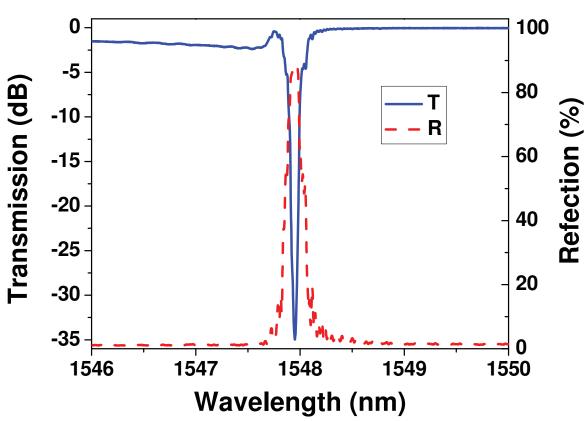
Writing beam intensity periodically modulated by acousto-optic modulator

H. Zhang et al., Opt. Lett. 32, 2559 (2007)







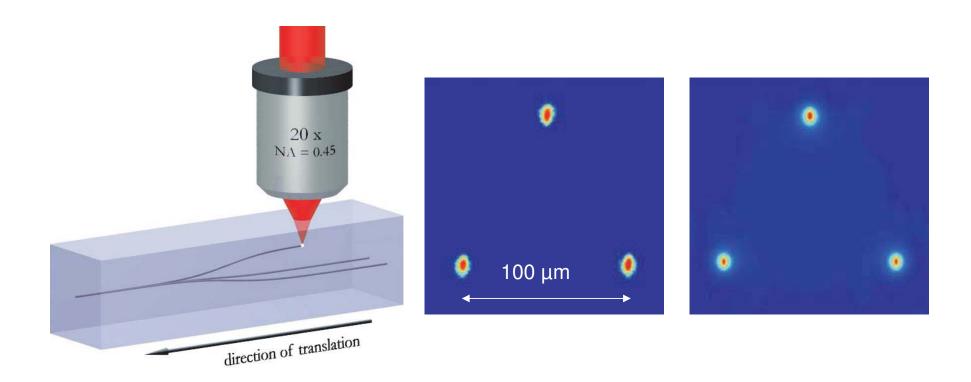


H. Zhang et al., Opt. Lett. 32, 2559 (2007)





Three-dimensional writing capabilities



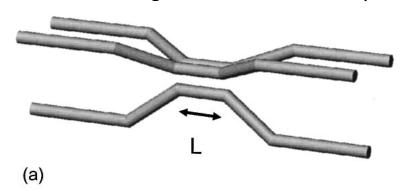
Three-dimensional splitter written in fused silica

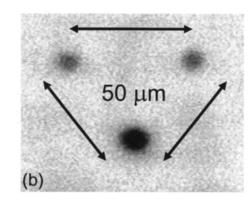
S. Nolte et al., Appl. Phys. A 77, 109 (2003)



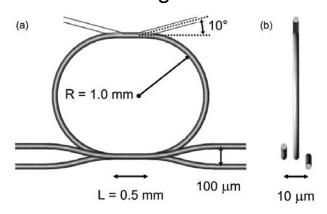


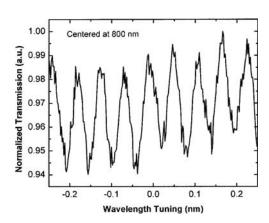
Three-waveguide directional coupler





3D microring resonator





A. M. Kowalevicz et al., Opt. Lett. 30, 1060 (2005)



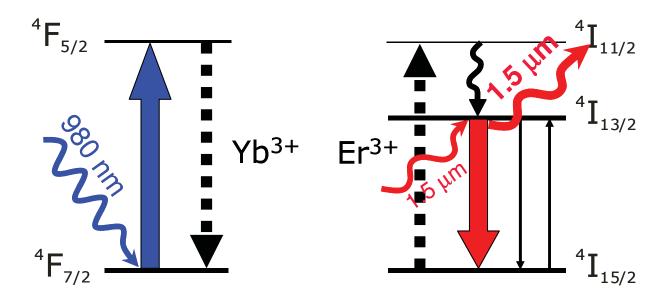


Active photonic devices by femtosecond writing





Substrate material: Er:Yb-doped phosphate glass

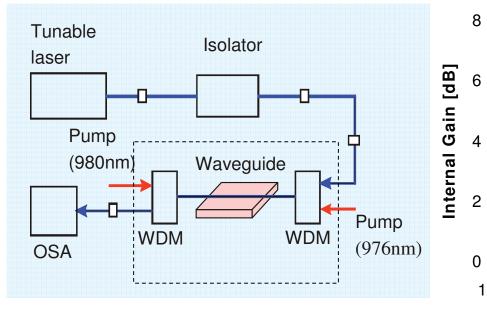


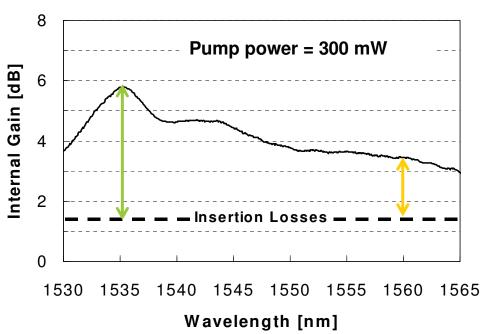
- Glass base suitable for compact active devices (high-gain per unit length)
- Allows for high doping concentration: 1-10 % weight Er₂O₃ or Yb₂O₃
- Three-level system, pumped at 980 nm and lasing at 1.5 μm in the telecom band





Active waveguides with net gain in the whole telecom C-band





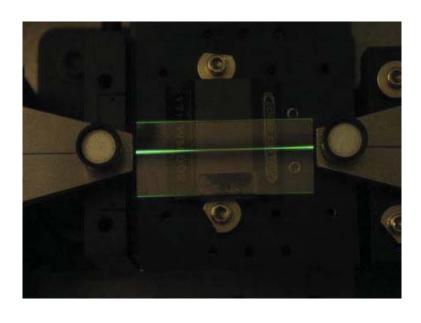
- Internal gain (6 dB) overcomes insertion losses (1.4 dB) over the whole C band
- Possibility of active devices such as waveguide amplifiers or lasers

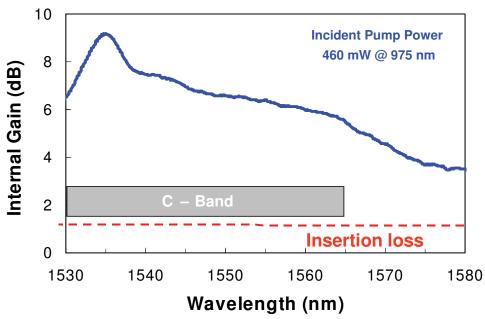
R. Osellame et al., Opt. Lett. 29, 1902 (2004)





Femtosecond laser written Erbium-Doped Waveguide Amplifier



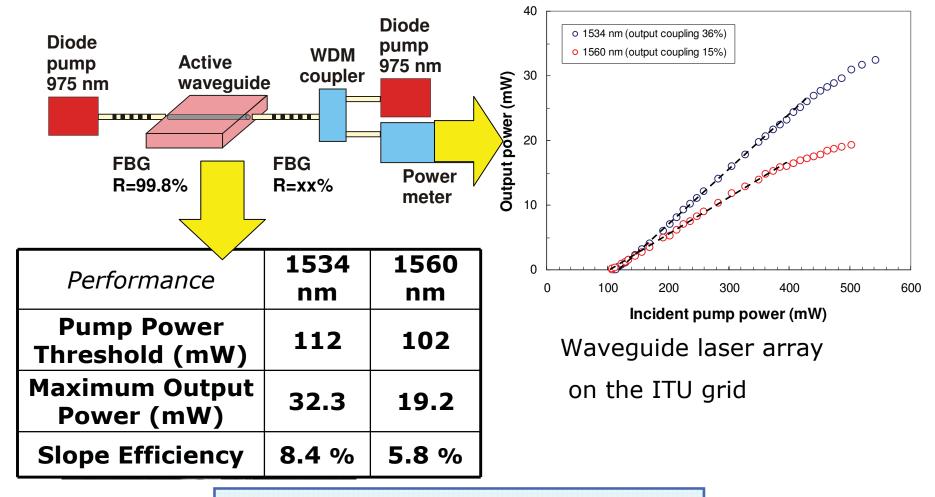


- Improved insertion losses (1.9 dB for L=37 mm → propagation loss < 0.4 dB/cm)</p>
- Gain over the whole C-band: 7.4 dB peak at 1535 nm,3.7 dB at 1565 nm
 - G. Della Valle et al., Opt. Express 13, 5976 (2005)





Femtosecond laser written waveguide laser

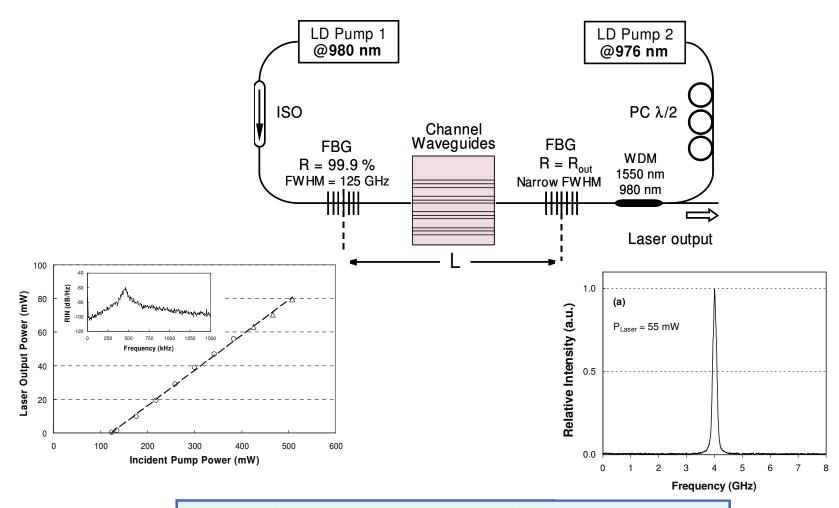


S. Taccheo et al., Opt. Lett. 29, 2626 (2004)





Single longitudinal mode waveguide laser

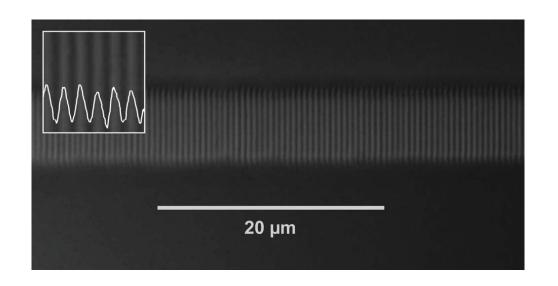


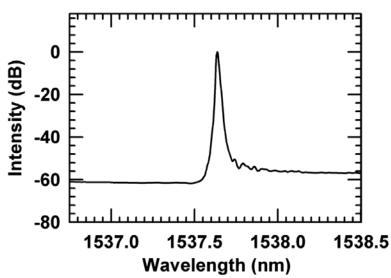
G. Della Valle et al., Opt. Express 15, 3190 (2007)





Waveguide laser with distributed feedback Bragg grating





Femtosecond laser written Bragg gratings integrated into the waveguide

G.D. Marshall et al., Opt. Lett. 33, 956 (2008)





Femtosecond laser microfabrication of waveguides for polarization encoded qubits





Quantum optical devices?

By properly tailoring the fabrication parameters, waveguides obtained by femtosecond laser irradiation are ideal candidates for the realization of integrated photonic quantum circuits

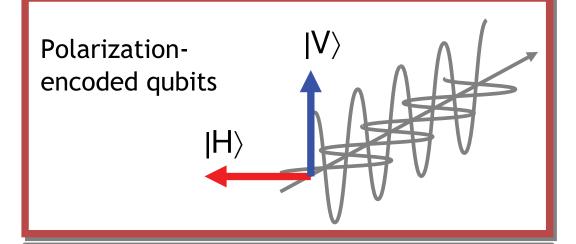
What do we need to change or optimize to meet the requirements of quantum circuits?

Photons entanglement must be preserved during the propagation





Waveguides for integrated quantum photonic circuits 43



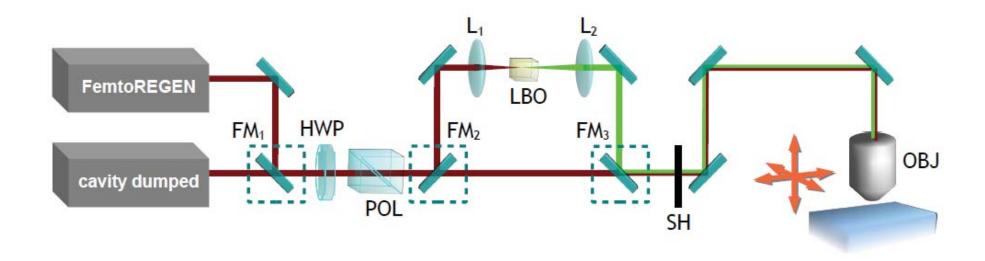
POLARIZATION ENCODING APPROACH

- most commonly adopted
- no need for path duplication (compactness)
- sources of entangled states



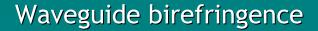


Waveguide writing set-up



- Femtosecond laser systems: cavity dumped oscillator or HighQLaser FemtoREGEN
- SHG stage can be inserted in line (LBO, lithium triborate crystal)
- Attenuation is performed by a half-wave plate (HWP) and a Glan-Thomson polarizer (POL)
- SH, mechanical shutter to block or enable the beam in the machining area
- The beam is focused into the substrate by a microscope objective (OBJ)
- 3D translation of the sample by computer-controlled high-precision stages





Decoherence, polarization mode dispersion

Deleterious effects on polarization encoded qubits

OPTIMIZATION OF THE WAVEGUIDE BIREFRINGENCE

SUBSTRATE CHOICE

- EAGLE2000 borosilicate glass
- fs-laser irradiation does not create birefringent nanostructures
- thermal effects (high repetition rates) circularize the waveguide

PARAMETERS OPTIMIZATION

Single mode guiding @806 nm

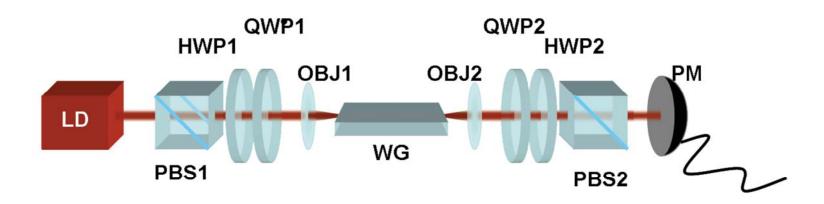
$$f_{rep} = 1MHz$$
 $\lambda = 1030nm$
 $E_{pulse} = 220 \text{ nJ}$
N.A. = 0.6 v = 40 mm/s

waveguide 2 µm cross-section

 $\Delta n_{\rm eff} = 7 \times 10^{-5}$







LD: laser diode @ 806 nm, $\Delta\lambda$ = 2 nm. PBS1 and PBS2: polarizing beam splitters. HWP1 and HWP2: half-wave plates. QWP1 and QWP2: quarter-wave plates. OBJ1 and OBJ2: objectives. PM: power meter.

Light with six different polarization states is injected into the waveguide. For each input state, the output state is projected on the same six polarization states. Normalized Stokes vector.





Polarization independent directional couplers

POLARIZATION INDEPENDENT DIRECTIONAL COUPLER

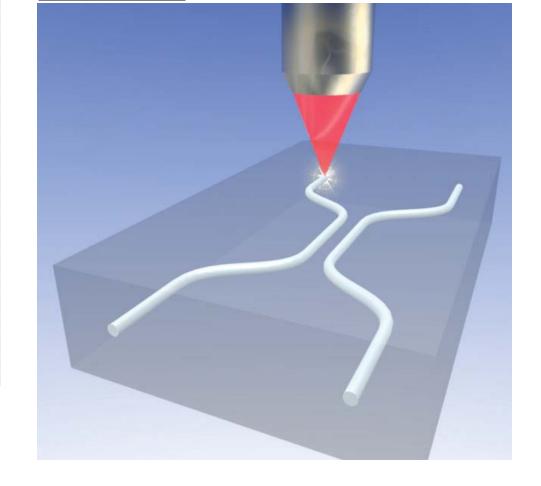
Integrated analogous of bulk beam splitter cube



basic component to exploit quantum interference

- Two modes are coupled by evanescent field
- Stable fiber coupling provided by pigtailing.

 $R_H = 49\%$ $R_V = 58\%$

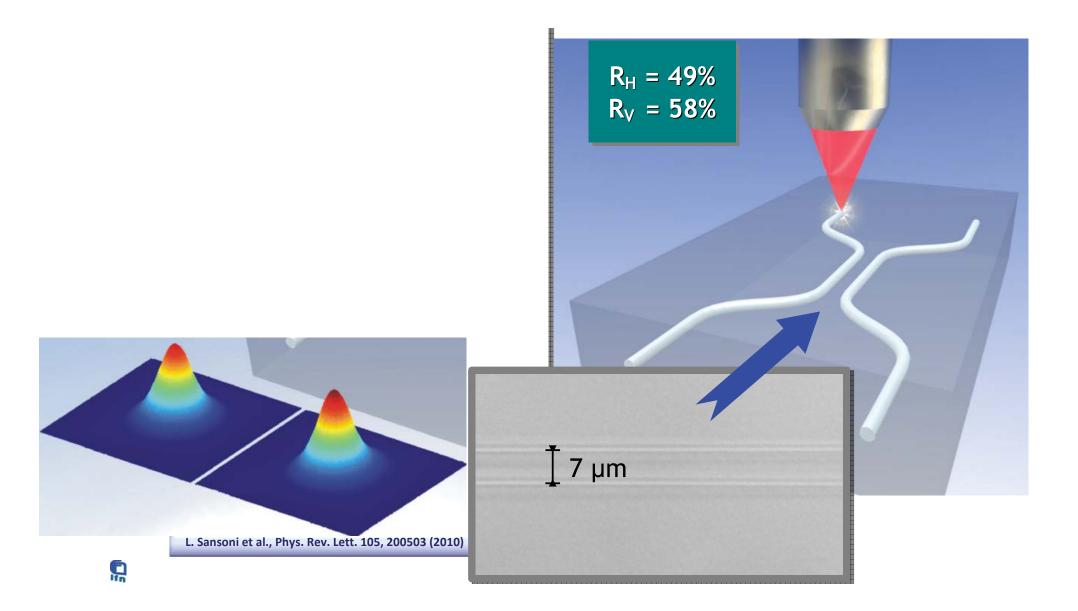


L. Sansoni et al., Phys. Rev. Lett. 105, 200503 (2010)





Polarization independent directional couplers



OUT2

OUT1



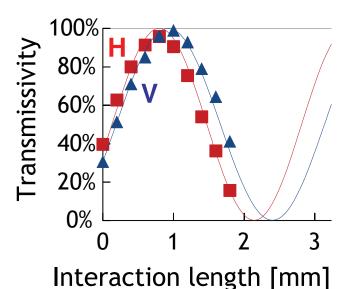
Partially polarizing directional couplers

Integrating polarization-encoded quantum gates: how to build partially polarizing directional couplers?

Directional coupler transmission as a function of the interaction length

$$T = \sin^2 \kappa L$$

The coupling coefficient is polarization dependent! (birefringence)



A. Crespi et al., Nature Comm., (2011)

Short interaction lengths: practical polarization insensitivity

Fabrication parameters		
Substrate	EAGLE2000	
Laser system	FemtoREGEN	
Wavelength	1040 nm	1000 A 40000
Repetition rate	960 kHz	10005. v #80000
Pulse energy	240 nJ	2 µm
Translation speed	20 mm/s	
Objective	0.45 NA	

@ L=7.4 mm $T_H = 0$ $T_V = 2/3$

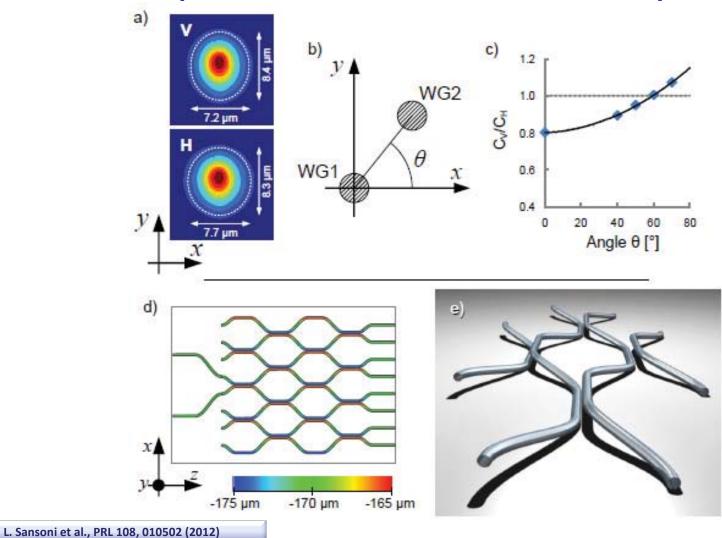
Enhanced and tailored polarization sensitive beahviour with greater interaction lengths





Integrated optical implementation

What to do when polarization insensitive directional couplers are needed?







- Femtosecond laser micromachining can produce low loss optical waveguides with excellent prototyping and 3D capabilities
- Depending on the substrate material both passive and active devices can be integrated
- Polarization behaviour of integrated waveguide directional couplers can be tailored
- Several applications fields can benefit from this powerful microfabrication technique, including quantum optics





Thank you for your attention

